AMENDMENTS TO THE CLAIMS:

- 1. (Canceled)
- 2. (Previously Presented) A silicon-containing polymer comprising the structure represented by formula 1 below as a main structural unit

$$(SiO_{4/2})_{k} (O_{1/2} Si - R^{2} - COOH)_{1} (O_{1/2} Si - R^{2} - COOR^{3})_{m} (O_{1/2} X)_{n}$$

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where R¹ represents a monovalent organic group, R² represents a direct bond or a divalent organic group, R³ represents a monovalent organic group or an organosilyl group, any of which groups may be of different types, X represents hydrogen, a monovalent organic group or an organosilyl group, which groups may be of different types, k and I are positive integers, m and n are 0 or positive integers, and these subscripts satisfy the following relationship

$$0 < \frac{1}{1+m+n} \le 0.8$$
 $0 \le \frac{m}{1+m} < 0.2$

wherein at least some of the X groups are triorganosilyl groups.

3. (Original) A silicon-containing polymer according to claim 2, wherein said triorganosilyl groups include photosensitive crosslinkable groups.

4. (Previously Presented) A silicon-containing polymer represented by formula 2 below,

where R¹ represents a monovalent organic group,

R² represents a direct bond or a divalent organic group,

R³ represents a monovalent organic group or an organosilyl group, any of which groups may be of different types,

X represents hydrogen, a monovalent organic group or an organosilyl group, which groups may be of different types, wherein at least some of the X groups are triorganosilyl groups containing a photosensitive crosslinkable group and wherein the photosensitive crosslinkable group is chloromethylphenylethyl,

 R^4 , R^5 and R^6 each independently represent a monovalent organic group, at least one of R^4 , R^5 and R^6 being a monovalent organic group containing chloromethylphenylethyl, wherein R^4 , R^5 and R^6 may be one or more different types of organic groups,

k, I and o are positive integers,

m and n are 0 or positive integers, and

these subscripts satisfy the following relationships:

$$0 < \frac{0}{1 + m + n + 0} \le 0.8$$

$$0 < \frac{1}{1+m+n} \le 0.8$$
 $0 \le \frac{m}{1+m} < 0.2$

(Previously Presented) A silicon-containing polymer comprising the 5. structure represented by formula 3 below as a main structural unit

$$(SiO_{4/2})_k (O_{1/2} \overset{R^1}{\underset{R^1}{\text{Si}}} - R^2 - COOH)_1 \quad (O_{1/2}X)_n \quad (O_{1/2} \overset{R^1}{\underset{Si}{\text{Si}}} - R^2 - COOR^7)_p \quad (O_{1/2} \overset{R^1}{\underset{Si}{\text{Si}}} - R^2 - COOR^8)_q \quad (O_{1/2} \overset{R^1}{\underset{R^1}{\text{Si}}} - R^2 - COOR^8)_q \quad (O_{1/2} \overset{R^1}{\underset{R^1}{\text{Si}}}$$

where R1 represents a monovalent organic group, R2 represents a direct bond or a divalent organic group, R7 and R8 each independently represent a monovalent organic group or an organosilyl group, any of which groups may be of different types, X represents hydrogen, a monovalent organic group or an organosilyl group, which groups may be of different types, k and q are positive integers, I, n, and p are 0 or positive integers, and these subscripts satisfy the following relationship

$$0 \le \frac{1}{1 + n + p + q} < 0. \quad 5$$

$$0 \le \frac{1}{1+n+p+q} < 0. 5 \qquad 0. 1 < \frac{q}{1+n+p+q} \le 0. 8$$

- 6. (Original) A silicon-containing polymer according to claim 5, wherein at least some of the X groups are triorganosilyl groups.
- 7. (Original) A silicon containing polymer according to claim 5, wherein R⁸ is a functional group that is eliminated by an acid catalyst.
- 8. (Currently Amended) A coplymer according to any one of claims 2 to 7, where R^2 is $-(Ch_2)_{a^-}$ and a is an integer of 1-10.
 - 9 17 (Cancelled)
- 18. (Previously Presented) A silicon-containing polymer comprising the structure represented by formula 1 below as a main structural unit

$$\begin{array}{c|c} R^{1} & R^{1} \\ (SiO_{4/2})_{k} (O_{1/2} \overset{R^{1}}{\underset{R^{1}}{\text{Si}}} - R^{2} - COOH)_{1} (O_{1/2} \overset{R^{1}}{\underset{R^{1}}{\text{Si}}} - R^{2} - COOR^{3})_{m} (O_{1/2} X)_{n} \end{array}$$

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where R¹ represents a monovalent organic group, R² represents a direct bond or a divalent organic group, R³ represents a monovalent organic group or an organosilyl group, any of which groups may be of different types, X represents hydrogen, a monovalent organic group or an organosilyl group, which groups may be of different types, k and I are positive integers, m is a positive integer, and n is 0 or a positive

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integer, and these subscripts satisfy the following relationship: $0 < I/(I+m+n) \le 0.8$ and 0 < m/(I+m) < 0.2.

- 19. (Previously Presented) A silicon-containing polymer according to claim18, wherein at least some of the X groups are triorganosilyl groups.
- 20. (Previously Presented) A silicon-containing polymer according to claim 19, wherein said triorganosilyl groups include photosensitive crosslinkable groups.
- 21. (Currently Amended) A coplymer according to any one of claims 18 to 20, where R^2 is $-(Ch_2)_{a^-}$ and a is an integer of 1-10.